Supplementary Information for

Achieving outstanding temperature and frequency stability in NaNbO₃ modified (Ba_{0.984}Li_{0.02}La_{0.04})(Mg_{0.04}Ti_{0.96})O₃ pulse energy storage ceramics

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E-mail addresses: fangbj@cczu.edu.cn (B. Fang), dingjn@cczu.edu.cn (J. Ding) Tel.: +86 519 86330095; Fax: +86 519 86330095 Eq. S1 The evolution route of electric tree:

$$p(i',j' \to i,j) = \frac{(\Phi_{i',j'} - \Phi_{i,j} - \Phi)^m}{\sum (\Phi_{i',j'} - \Phi_{i,j} - \Phi)^m} + (\Phi_{i',j'} - \Phi_{i'',j''} - \Phi)^m - loss$$

where $\Phi_{i,j}$, $\Phi_{i',j'}$, and $\Phi_{i'',j''}$ are the electric potential of the discharge, probable, and linked point, respectively. Φ represents the threshold electrical potential of grain and grain boundary, *loss* denotes the loss of the tip electrical tree channels, and *m* is the fractal dimension.

 Table S1
 The fitting parameters of the fractal dielectric breakdown model and

percolation model.

parameter	x=	0	<i>x</i> =0.15		
area	30×40 um ²		$6 \times 8 \text{ um}^2$		
Grid points	150×200		150×200		
	Grain	Grain boundary	Grain	Grain boundary	
φ ₀	2.18	6.33	0.36	1.28	
Loss	0.0108	0.0621	0.0037	0.0124	
η	1.0	1.0	1.0	1.0	

Table S2 The *BDS*, average grain size, E_g , R_b , R_{gb} value of (1-x)BLLMT-xNN

x	BDS (kV/cm)	Average grain size (µm)	$E_{\rm g}({ m eV})$	<i>R</i> _b (Ω) at 410 °C	<i>R</i> _{gb} (Ω) at 410 °C
0.05	352.6	0.24	3.71		3.89×10^{6}
0.1	324.9	0.2	3.69		3.73×10^{6}
0.15	407.7	0.18	3.59		8.93×10 ⁵
0.2	362.2	0.22	3.64		5.38×10^{6}
0.4	337.6	0.54	3.16	4.44×10 ⁵	4.22×10^{6}
0.6	310.4	2.21	2.73	2.81×10^{5}	1.61×10^{6}

samples.



Fig. S1. Raman spectra and the spectral deconvolution into Gaussian-Lorentzian-

shape peaks of the 0.4BLLMT-0.6NN ceramics.



Fig. S2. Rietveld refinement results of the (1-*x*)BLLMT-*x*NN samples. (a) x=0.05; (b) x=0.1; (c) x=0.15; (d) x=0.2; (e) x=0.4; (f) x=0.6.



Fig. S3. The distribution of grain size and average grain size of the (1-x)BLLMT-xNN

samples. (a) *x*=0.05; (b) *x*=0.1; (c) *x*=0.15; (d) *x*=0.2; (e) *x*=0.4; (f) *x*=0.6.







Fig. S4. Temperature dependence dielectric constant and dielectric loss of (1-

x)BLLMT-*x*NN samples.



Fig. S5. The complex impedance spectra of the (1-x)BLLMT-xNN samples measured

at 410-450 °C. (a) *x*=0.05; (b) *x*=0.1; (c) *x*=0.15; (d) *x*=0.2; (e) *x*=0.4; (f) *x*=0.6.



Fig. S6. The equivalent circuits of different impedance spectra.



Fig. S7. The ultraviolet visible absorbable spectrum of the (1-x)BLLMT-xNN

samples.



Fig. S8. (a) The SEM micrograph of pure BLLMT ceramics. The grain models used for finite element simulation achieved by machine learning using SEM micrograph of

(b) *x*=0 and (c) *x*=0.15.



Fig. S9. The simulated electric field distribution and growth of electrical tree for (a_1) x=0 and (b_1) x=0.15. The simulated electric potential distribution for (a_2) x=0 under 360 kV/cm and (b_2) x=0.15 under 409 kV/cm.



Fig. S10. The *P-E* loops of the (1-x)BLLMT-xNN samples measured at un-breakdown

state and 20 Hz.



Fig. S11. Overdamped discharge current curves of the (1-*x*)BLLMT-*x*NN samples tested at different electric fields and 150 Ω . (a) *x*=0.05; (b) *x*=0.1; (c) *x*=0.15; (d) *x*=0.2;

(e) *x*=0.4; (f) *x*=0.6.



Fig. S12. Out-of-plane PFM images of the 0.85BLLMT-0.15NN sample measured at

different electrical voltages.



Fig. S13. Comparison of domain structure for pure BLLMT sample and 0.85BLLMT-

0.15NN sample measured at ± 5 V.